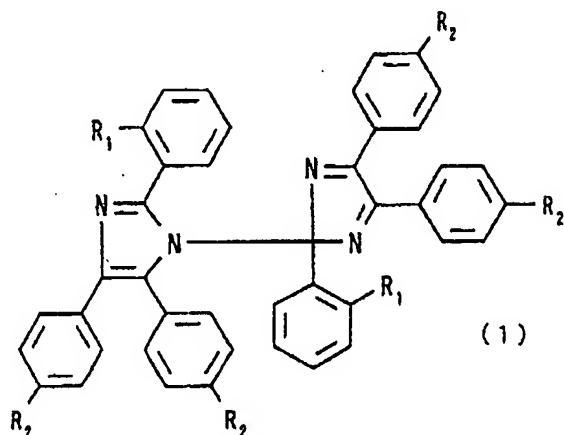


ABSTRACT

The present invention provides a novel hexaarylbiimidazole
5 compound of the following formula (1):



10 wherein each R₁ represents a halogen, and each R₂ represents an
optionally substituted C₁₋₄ alkyl group. The hexaarylbiimidazole
compound of the present invention is useful as a photoradical
generator in photopolymerizable compositions used as resists and is
characterized by low sublimating thermal decomposition products.
15 The photopolymerizable compositions may be suitably used as resists or
as color filters for color liquid crystal display elements, cameras and
the like.